

ABSTRACT

INFRARED REFLECTING SUBSTRATE

Infrared reflecting substrate (100) includes, on a transparent film base (10), an
5 infrared reflecting layer (23) mainly made of silver and a light absorptive metal
layer (25) in this order. The light absorptive metal layer (25) has a thickness of 15
nm or less, and a transparent protective layer (30) has a thickness of 10 nm to 120
nm. The distance between the light absorptive metal layer (25) and the transparent
protective layer (30) is 25 nm or less. The infrared reflecting substrate having low
10 visible light reflectance, excellent visibility and excellent productivity is provided by
the present invention.

Figure 1